

PHOTOCHEMISTRY OF NITROMETHANE ADSORBED ON ALKALI HALIDE FILMS

TONI GREEN, ANGELA JARAMILLO, GERALD WAYTON, and C.A. BAUMANN, *Department of Chemistry, University of Scranton, Scranton, PA 18510.*

Nitromethane was adsorbed at low temperature onto sublimated alkali halide films. Irradiation of the adsorbate at wavelengths below 250 nm produced a variety of photoproduct species. We have identified a number of the primary photoproducts (CH_3ONO , H_2CO , HNO) as well as species resulting from secondary photolysis (CO , N_2O). The quantum efficiencies for production of these species were determined as a function of irradiation wavelength and surface temperature.